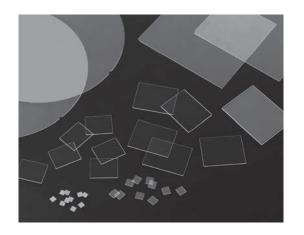
# Flat Glass for Electronic Devices

We offer flat glass with various properties for electronic devices. You can choose the glass that is most suitable for the purpose of use.

#### **Features**

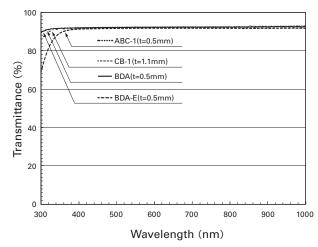
- 1. High quality glass is manufactured using advanced technology.
  - •Technology for achieving very smooth glass surfaces
  - •Technology to achieve higher surface cleanliness
- 2. BDA-E with excellent chemical resistance can be used for a wide range of electronic devices.
- 3. CB-1 with a thickness of 1.1 mm can be used for a wide range of electronic devices.
- 4. ABC-1 is a low expansion alkali-free glass.
- 5. BDA is a glass exclusively developed not to influence the pixels of high-density image sensors.



#### **Properties**

Properties/Glass Code			CB-1	ABC-1	BDA
n 30-380°C	×10-7/K	69	75	37	66
Strain point		530	525	685	540
Annealing point		570	560	745	575
1MHz, 25°C		6.8	6.9	5.6	6.5
1MHz, 25°C	×10-4	100	100	10	100
JIS R3502	R <sub>2</sub> Omg	0.05	0.08	< 0.01	0.07
λ=500nm, t=0.5mm	%	92	92	92	92
Refractive index (n <sub>d</sub> )		1.52	1.51	1.53	1.51
	×10 <sup>3</sup> kg/m <sup>3</sup>	2.46	2.47	2.52	2.44
)	1MHz, 25°C 1MHz, 25°C JIS R3502 λ=500nm,	10 30-380°C ×10-7/K °C °C °C 1MHz, 25°C ×10-4 JIS R3502 R2Omg λ=500nm, t=0.5mm %	n 30-380°C ×10-7/K 69  °C 530  °C 570  1MHz, 25°C 6.8  1MHz, 25°C ×10-4 100  JIS R3502 R2Omg 0.05  λ=500nm, t=0.5mm % 92  1.52	30-380°C   ×10-7/K   69   75     °C   530   525     °C   570   560     1MHz, 25°C   6.8   6.9     1MHz, 25°C   ×10-4   100   100     JIS R3502   R <sub>2</sub> Omg   0.05   0.08     λ=500nm, t=0.5mm   %   92   92	$\begin{array}{c ccccccccccccccccccccccccccccccccccc$

### **Transmittance**



## **Dimension example**

	Dimensions	Thickness	Tolerance of thickness	
BDA-E	2×2 ma ma 260×440 ma ma	0.1-1.1mm		
CB-1	2×2mm-360×440mm	1.1mm	± 0.01- ± 0.1mm	
ABC-1	Ф100-300mm	0.3-0.5mm		
BDA	2×2mm-50×50mm	0.3-0.7mm		

Various optical coatings can be designed as requested.